## Synthesis, structural characterization and electronic properties of V<sub>2</sub>CT<sub>x</sub> MXene nanosheets

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A new family of 2D materials has emerged, consisting of transition metal carbides, nitrides, and carbonitrides, also known as MXenes. The vast majority of MXenes known to date have been produced by selectively etching AI from Alcontaining MAX phases.<sup>[1]</sup> During the the MXene surface etching process, acquires terminating functional groups, which why they are is commonly designated as  $M_{n+1}X_nT_x$ , where  $T_x$  represents surface terminating groups such as -O, -OH, and/or -F, as shown in Fig1(a).<sup>[2-3]</sup>

Herein, two-dimensional  $V_2CT_x$ nanosheets were obtained by chemical exfoliation of as-grown V<sub>2</sub>AIC single crystals <sup>[4]</sup> in 40% HF solution at room temperature. The influence of etching time on the synthesis and structural evolution were studied. The paper-like structure of asprepared V<sub>2</sub>CT<sub>x</sub> nanosheets was confirmed by SEM and micro-Raman, as shown in Fig1(b,c).

Following a mechanical exfoliation, thin flakes have V<sub>2</sub>CT<sub>x</sub> been successfully transferred on Si/SiO<sub>2</sub> substrates. In order to measure electrical transport of astransferred V<sub>2</sub>CT<sub>x</sub> flake, e-beam lithography techniques were applied to pattern electrical contacts on top of the flakes, as shown in Fig1(d). Electrical properties of V<sub>2</sub>CT<sub>x</sub> flakes were obtained for a range of temperature between 4K and 300K temperature range were tested. Individual V<sub>2</sub>CT<sub>x</sub> flakes exhibits metallic behavior. Maanetotransport down to low temperature allows to extract intrinsic properties, which charge carrier are compared with bulk MXene and MAX phases values. DFT calculation were performed and compared with the experimental results.

## References

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**Figure 1:** (a) Structure of terminated V<sub>2</sub>CT<sub>x</sub> MXenes (b)SEM image of V<sub>2</sub>AIC after etching 96h, showing the highly delaminated paper-like layered structure V<sub>2</sub>CTx; (c) Raman spectra of V<sub>2</sub>CT<sub>x</sub> nanosheets on the Si/SiO<sub>2</sub> substrates;(4) Electrical contact pattern of V<sub>2</sub>CT<sub>x</sub> nano device